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## ZnO/SnS复合薄膜的制备及其光伏性能

伍丽,史伟民,张兆春,秦娟,王林军,魏光普,夏义本

(上海大学 材料科学与工程学院,上海 200072)

## Fabrication and Photovoltaic Properties of ZnO/SnS Coextruded Films

WU Li,SHI Wei-min,ZHANG Zhao-chun,QIN Juan, WANG Lin-jun,WEI Guang-pu,XIA Yi-ben (School of Materials Science and Engineering, Shanghai University, Shanghai 200072, China)

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摘要

利用n型氧化锌和p型硫化亚锡制备ITO/ZnO/SnS/Al结构的pn结太阳能电池.首先采用射频磁控溅射法在ITO衬底上制备ZnO薄膜,再 用真空蒸发镀膜法沉积SnS薄膜以形成异质结,并利用X射线衍射(X-ray diffraction,XRD)光谱、透射光谱和I-V曲线来表征薄膜和器 件的性能. 讨论在不同溅射功率和工作气压下制备的ZnO薄膜对光吸收情况和所形成异质结器件的影响,测量不同沉积时间制备的ZnO 薄膜相应的器件的开路电压、短路电流密度和填充因子.结果表明,当工作气压和溅射功率分别为0.2 Pa和150 W,沉积时间为40 min 时得到的ZnO薄膜能获得较好的异质结且器件的性能达到最优化.该最优器件的短路电流密度 $J_{SC}$ 为1.38  $\mathsf{mA} \cdot \mathsf{cm}^{-2}$ ,开路电压 $V_{OC}$ 为 0.42 V,填充因子F<sub>F</sub>为0.40.

关键词: 太阳能电池; SnS; ZnO; 真空蒸发; 磁控溅射

Abstract.

The n type ZnO and p type SnS were used to prepare solar cells with the structure of ITO/ZnO/SnS/Al. The n-ZnO thin films were first obtained on the ITO substrate by using RF magnetron sputtering with different working pressures and sputtering powers. The p SnS thin films were then deposited on the n ZnO layers by vacuum evaporation. Qualities of ZnO thin films were analyzed with an ultraviolet visible spectrophotometer (UI/VIS) and the properties of heterojunctions were measured with X ray diffraction (XRD). The photoelectric properties of SnS/ZnO heterojunction solar cells were characterized with I-V curves. As a result, a better solar cell was prepared with the fabrication of n ZnO under 0.2 Pa working pressure, 150 W sputtering power and 40 min depositing time. The cell parameters are:  $J_{SC}$  =1.38 mA • cm-2,  $V_{OC}$  =0.42 V,  $F_E$ =0.40.

Keywords. solar cell; SnS; ZnO; vacuum evaporation; magnetron sputtering

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Email: wmshi@mail.shu.edu.cn 通讯作者 史伟民(1951~),男,教授,研究方向为功能材料与器件.

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